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Synthesis of ZnO/Bi₂O₃ and SnO₂/Bi₂O₃/Bi₂O₄ mixed oxides and their

photocatalytic activity

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Abstract

In the present work, ZnO/Bi₂O₃, SnO₂/Bi₂O₃/Bi₂O₄ mixed oxide, Bi₂O₃ rod-like and SnO₂ nanoparticle have been synthesized. The obtained samples were characterized by field emission scanning electron microscopy (FE-SEM) and X-ray diffraction (XRD). The optical properties of samples were evaluated by UV-Vis spectrophotometer. The photocatalytic activity of samples was evaluated by decolorization of methylene blue (M.B.) solution. The Present work indicates the improving or hampering effect of Bi₂O₃ on the photocatalytic activity of ZnO/Bi₂O₃. The results show that the photocatalytic performance of ZnO/Bi₂O₃ which is higher than that of Bi₂O₃, SnO₂, and SnO₂/Bi₂O₃/Bi₂O₄ is related to the presence of the zinc oxide semiconductor. Furthermore, results indicated that the photoactivity of the SnO₂/Bi₂O₃ system was not improved. The present work affirms the importanat position of energy levels and also the separation of photogenerated electron/hole pairs on the efficient photocatalytic performance.

Keywords: Mixed oxide; Photocatalyst; Semiconductor; ZnO/Bi₂O₃; SnO₂/Bi₂O₃/Bi₂O₄.

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Introduction

Removal of organic pollutants in wastewater is an important measure of environmental protection. Advanced oxidation processes (AOPs) provide a promising technique for the treatment of textile industry wastewater. The photocatalytic process, based on UV-Vis irradiated semiconductor, represents one of AOPs that provide an interesting route to the destruction of many organic substances of CO₂, H₂O, and corresponding mineral acids. When the semiconductor is illuminated by a photon of energy equal or higher than the band gap energy, electrons in the conduction band (e_{CB}) and holes in the valence band (h^+_{VB}) are produced. These charge carriers can recombine, or the holes can be scavenged by oxidizing species (for example, H_2O , $OH^$ and electrons can be consumed by). reducible species (for example, O₂) in the solution. The hydroxyl radical (•OH) is a highly reactive oxidizing reagent and can decompose most organic contaminants. So far, various kinds of compound materials, such as metal oxide and nanocomposites have been widely used as a photocatalyst [1-10]. In the present study, $SnO_2/Bi_2O_3/Bi_2O_4$, ZnO/Bi₂O₃ mixed oxide, Bi₂O₃ rod-like and SnO₂ nanoparticle have been synthesized. The photocatalytic activity of the prepared samples was evaluated by the decolorization

of methylene blue (M.B.) solution under the UV-Vis irradiation.

Experimental

General

All the analytical chemicals were purchased from Merck and used without further purification. The detailed synthesis procedure is as follows:

Synthesis procedure for Bi₂O₃ preparation

The synthesis of Bi_2O_3 used for this study fundamentally followed a method reported previously by Wang et al. [11]. First, 200 mL of (0.2 M) NaOH solution was prepared (Solution I). Second, 2 g of Bi(NO₃)₃.5H₂O was dissolved in 20 mL of the 1 M nitric acid solution (Solution II). Then, the solution (II) was added drop wise into the solution (I) under constant stirring. After stirring the mixture for 30 min at 80 °C, the product was separated by decantation, washed with double distilled water several times and dried at 60 °C. Then, heat treatment of the product was carried out at 600 °C for 1 h. **Synthesis** procedure for ZnO/Bi_2O_3 preparation

First, 0.5 g of the commercial Zinc oxide was dispersed in 50 mL of the 0.2 M NaOH solution (Solution I). Second, 0.5 g of the $Bi(NO_3)_3.5H_2O$ was dissolved in 5 mL of the 1 M nitric acid solution (Solution II). Then, the solution (II) was added drop wise into the solution (I) under constant stirring. After stirring the mixture for 30 min at 80 °C, the product was separated by decantation, washed with double distilled water several times and dried at 60° C. Then, heat treatment of the product was carried out at $6 \ 0 \ 0$ °C for 1 h.

Synthesis procedure for preparing SnO₂

The SnO₂ nanoparticle was synthesized by the solid state method [12]. The SnCl₂. $2H_2O$ (2.2 g) and NaOH (0.8 g) were mixed in an agate mortar and were thoroughly grounded for 60 min at room temperature. The product was washed with double distilled water several times and dried at 60 °C. Then, heat treatment of the product was carried out at 900 °C for 1 h.

Synthesis procedure for $SnO_2/Bi_2O_3/Bi_2O_4$ preparation

First, 0.5 g of the prepared tin oxide was dispersed in 50 mL of the 0.2 M NaOH solution (Solution I). Second, 0.5 g of Bi(NO₃)₃.5H₂O was dissolved in 5 mL of the 1M nitric acid solution (Solution II). Then, the solution (II) was added drop wise into the solution (I) under constant stirring. After stirring the mixture for 30 min at 80 °C, the product was separated by decantation, washed with double distilled water several times and dried at 60 °C. Then, heat treatment of the product was carried out at

600 °C for 1 h. Evaluation of photocatalytic activity

A high pressure lamp (400W Hg) manufactured by Holland Philips, was used as the light source. Air was blown into the reaction by an aquarium pump to maintain the solution saturated with oxygen during the course of the reaction. In each experiment, 0.05 g of each prepared photocatalyst was added in 100 mL of the methylene blue solution (10 ppm). During irradiation, agitation was maintained by a magnetic stirrer to keep the suspension homogeneous. The suspension was sampled at regular intervals and immediately centrifuged to remove catalyst particles completely. Then, the degree of photo decolorization (X), as a function of time, is given by X = (C - C)/C, where, C is the initial concentration of dye, and C is the concentration of dye at time t. The progress of photocatalytic decolorization was measured by a UV-Vis spectrophotometer (Shimadzu UV-2550). The disappearance of peak at = 663 nm was chosen for monitoring of dye decolerization for a methylene blue solution (M.B.). Results and discussion The structure and morphology of the product were characterized by using XRD (Holland Philips Xpert, X-ray diffractometer with Cu-K radiation) and field emission scanning

electron microscope (FE-SEM) (Hitachi S-4160) with gold coating. XRD results (Figure 1a) confirmed that the -Bi₂O₃ (monoclinic, JCPDS No. 01-071-2247) was obtained by heat treatment at 600 °C for 1h. XRD results (Figure 1b) revealed that the SnO₂ (tetragonal, JCPDS No. 21-1250) was obtained.



Figure 1. XRD patterns of the samples (a) $-Bi_2O_3$ (b) SnO_2 (c) ZnO/Bi_2O_3 (d) SnO_2/Bi_2O_4



Figure 2. FE-SEM images of the samples (a) $-Bi_2O_3$ (b) SnO_2 (c) ZnO/Bi_2O_3 (d) $SnO_2/Bi_2O_3/Bi_2O_4$

Figure 1C shows the XRD patterns of the ZnO/Bi₂O₃ prepared after heat treatment at 600 °C. As shown in XRD pattern monoclinic and tetragonal phase (JCPDS No. 00-029-0236, JPDS No. 01-071-2274) were observed for the Bi₂O₃. In addition, wurtzite phase was observed for the ZnO (JCPDS No. 01-079-2205). The structure of $SnO_2/Bi_2O_3/Bi_2O_4$ composite was investigated by the XRD pattern (Figure 1d). As shown in the XRD pattern monoclinic phase was observed for $-Bi_2O_3$ (JCPDS No. 71-0465) and Bi₂O₄ (JCPDS No. 50-0864). In addition, tetragonal phase was observed for the SnO₂ (JCPDS No. 21-1250). The morphology of the samples was studied by FE-SEM (Figure 2). Figure 2a and Figure 2b show that the morphology of the Bi_2O_3 and SnO₂ samples are rod-like and nanoparticle respectively. Figure 2c illustrates that the surface of ZnO/Bi₂O₃ sample consists of nanoparticles with average size of 15.7 nm. indicates Figure 2d that the SnO₂/Bi₂O₃/Bi₂O₄ sample consists of rods with average length of 3.4 µm and nanoparticles with average size of 57.5 nm. In this work methylene blue solution was chosen as the environmental pollutant. The

results in figure 3 showed that, the dye adsorption on the surface of the prepared photocatalysts is poor after 120 min in the dark (Figures. 3a, 3b, 3c, 3d and 3e).

Figure 3f, 3g, 3h, 3i and 3j show the UV-Vis spectra changes during the light irradiation. As can be seen, Zinc oxide is a well-known photocatalyst. So far, several papers have been published on the bare zinc oxide photocatalytic activity [13-17]. In this photocatalytic activity work, the of ZnO/Bi₂O₃ sample and commercial zinc oxide have been compared. These experiments indicate whether Bi₂O₃ is improving or hampering the photocatalytic activity of ZnO/Bi_2O_3 and whether commercial zinc oxide still has the highest activity or not. The photocatalytic decolorization results show that the ZnO and ZnO/ Bi₂O₃ samples can degrade 99 and 95% of cationic M.B. dye solution after 120 min under UV-Vis irradiation respectively (Figure 4). It should be noted that the adsorption of M.B. solution on the surface of the samples is at about 8% after 120 min in the dark. According to the photocatalytic experiments, commercial zinc oxide still has the highest activity.







Figure 4. Adsorption and decolorization percentage of (M.B.) solution in the presence of prepared photocatalysts

To have a quantitative estimate of the photocatalytic activity of the prepared samples the optical band gap via the Tauc Equation was employed_($hv = A(hv - E_g)$). In this equation is the absorption coefficient, hv is the photon energy, E_g is the optical band gap, A which is a constant does not depend on the photon energy and has four numeric values $(\frac{1}{2}$ for allowed direct transitions, 2 for the allowed indirect, 3 for forbidden direct and $\frac{3}{2}$ for forbidden indirect optical transitions) [18, 19]. In this work, the direct transition band gap (E_g) of the samples was determined by plotting $(hv)^2$ versus h

curve with the extrapolation of the linear region to $(hv)^2 = 0$ [20, 21]. Figure 5 (**a-c**) illustrates the $(hv)^2$ vs. hv for Bi₂O₃, ZnO and ZnO/Bi₂O₃ samples. The values of band gap for Bi₂O₃ and ZnO are found to be 2.8 eV. and 3.4 eV. respectively. Figure 5d presents UV-Vis spectra of the Bi₂O₃, ZnO and ZnO/Bi₂O₃ samples. As shown the commercial zinc oxide, Bi_2O_3 . and ZnO/Bi₂O₃ have a broad peak at about 361-460 nm. The Figures 6a and 6b show the $(hv)^2$ vs. hv for SnO₂ and SnO₂/Bi₂O₃/Bi₂O₄ samples. The value of band gap for SnO₂ and SnO₂/Bi₂O₃/Bi₂O₄ is found to be 2.8 eV. Figure 6c illustrates UV-Vis spectra of the

Bi₂O₃, SnO₂ and SnO₂/Bi₂O₃/Bi₂O₄ samples. According to Figure 5c, for ZnO/Bi₂O₃ composite two band gap values (2.8 eV. and 3.4 eV.) are observed. These values are related to bare Bi_2O_3 and ZnO respectively. Figure 6b shows that the band gap value of the $SnO_2/Bi_2O_3/Bi_2O_4$ composite is 2.8 eV.



Figure 5. The plot of $(h)^2$ versus h, (a) ZnO, (b) Bi_2O_3 , (c) ZnO/ Bi_2O_3 composite, (d) UV-Vis absorbance spectra of the ZnO, Bi_2O_3 and ZnO/ Bi_2O_3 samples

The photoluminescence spectrum (PL) of commercial zinc oxide is shown in Figure 7. The emission bonds show a strong and broad UV-blue emission at about (393-440 nm) and a weak green emission at about 508 nm. UV emission is due to the recombination of the generated electrons and holes, related to the near-band edge emission.

Luminescence spectroscopy is known to be an effective method for evaluation of surface defects and optical properties. Generally, the blue and blue-green emissions are possibly due to the surface defects and the green emission corresponds to the singly ionized oxygen vacancy in the zinc oxide [21-23].



Figure 6. The plot of $(h)^2$ versus h, (a) SnO₂, (b) SnO₂/Bi₂O₃/Bi₂O₄ composite, (c) UV-Vis absorbance spectra of the SnO₂, Bi₂O₃ and SnO₂/Bi₂O₃/Bi₂O₄ samples



Figure 7. The PL spectrum of commercial zinc oxide

Deep level emission is related to various defects such as zinc interstitials (Zn_i), oxygen vacancies (V_O), Zn vacancies (V_{Zn}), and antisite-defect oxygen substitution zinc (O_{Zn}) [24, 25]. The interstitial Zn (Zn_i), (~ 0.4-0.5

eV.) is located at the bottom of the conduction band. Hence, interstitial Zn (Zn_i) acts as an electron acceptor [26, 27]. The interstitial Zn (Zn_i) defect inhibits recombination of photogenerated hole (h^+)



and electron (e), therefore, commercial zinc



Figure 8 and Figure 9 show the mechanism of the charge separation and photocatalytic reaction for the ZnO/Bi₂O₃ SnO_2/Bi_2O_3 semiconductors. and As illustrated in the scheme. when the composites are irradiated by the UV light with the photon energy higher than that of the ZnO and SnO₂ band gaps, electrons in the valence band (VB) are excited to the conduction band (CB) with the simultaneous generation of the same amount of holes (h⁺) in the VB. The Bi_2O_3 has a relatively narrow band gap (2.8 eV.). As the position of conduction band of $-Bi_2O_3$ (E_{CB}=+0.33 eV., E_{VB} =+3.13 eV.) is lower than that of ZnO $(E_{CB}=-0.3 \text{ eV}., E_{VB}=+2.9 \text{ eV}.)$ [26, 27] it can act as a photoelectronic receiver as represented in Figure 8.

oxide has the highest photocatalytic activity.





The valence band position of the ZnO is more positive than the standard redox potential of ($^{\circ}OH/OH^{-} = 1.99 \text{ eV.}$, vs. NHE) [28], suggest that the generated holes in the valence band of ZnO can oxidize OH⁻ or H₂O to form •OH, which is then involved in the photocatalytic degradation of M.B. solution. The conduction band edge potential of - Bi_2O_3 (+0.33 eV.) which is more positive than the standard redox potential $(O_2/O_2^- = -$ 0.33 eV., vs. NHE) and $(O_2/{}^{\bullet}HO_2=-0.046)$ eV., vs. NHE) [29, 30], suggest that the electrons in the conduction band of -Bi₂O₃ cannot reduce O_2 to $\bullet O_2^-$ and $\bullet HO_2$. However, the accumulated electrons in the conduction band of $-Bi_2O_3$ can be transferred to O_2 adsorbed on the surface of the composite semiconductors and H₂O₂ yields because the conduction band level of -Bi₂O₃ is more

negative than the standard redox potential $(O_2/H_2O_2=+0.682 \text{ eV.}, \text{ vs. NHE})$ [31]. The above processes initiate photocatalytic oxidation reactions. As the position of the conduction band of SnO₂ (E_{CB}=+0. 4 EV., E_{VB} =+4. 2 eV.) is slightly lower than that of $-Bi_2O_3$ (E_{CB}=+0.33 eV., E_{VB}=+3.13 eV.) [25], it can acts as a photoelectronic receiver as represented in Figure 9. Conversely, the holes transfer from the VB of SnO₂ to that of Bi₂O₃. The photogenerated electrons and holes in the composite could be injected into a reaction medium and participate in chemical reactions. The SnO₂/Bi₂O₃ system inhibited recombination the of photogenerated hole (h^+) and electron (e^-) in Bi_2O_3 . But results show that the photoactivity of the SnO₂/Bi₂O₃ system was not improved. To sum up, position of energy levels and separation of photogenerated electron/hole efficient pairs are important for the photocatalytic performance. In present study the reusability of ZnO/Bi₂O₃ has also been investigated. At the end of each cycle the ZnO/Bi₂O₃ catalyst was washed with double distilled water and a fresh solution of methylene blue was added before each photocatalytic run. The decolorization rates for the five cycling reuse were 100, 98, 95 and 90 % after 120 min of reaction time (Figure 10).



Figure 10. Reusability of the ZnO/Bi₂O₃ composite

Conclusion

In conclusion, the SnO₂/Bi₂O₃/Bi₂O₄, ZnO/Bi₂O₃ nanocomposites, Bi₂O₃ rods and SnO₂ nanoparticle have been synthesized using the simple route. The present work shows that the photocatalytic performance of the ZnO/Bi_2O_3 is higher than that of Bi_2O_3 , SnO₂ and SnO₂/Bi₂O₃/Bi₂O₄ which is related to the presence of zinc oxide. The enhancement of the photocatalytic activity is attributed to the energy level position and separation of photogenerated electron/hole pairs.

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